
ERRATUM

Tunneling into Weakly Coupled Films of Tins and Aluminum in Proximity. II. From the Tin Side, J. Vrba and S. B. Woods [Phys. Rev. B 4, 87 (1971)]. Some lines of this article were misplaced during the page makeup procedure.

(i) The right-hand column of p. 92 should be read: "...ture dependence of the McMillan peak structure (see Fig. 2) and the BCS temperature dependence of the gap edge in the aluminum electrode. The results of a typical experiment are plotted in Fig. 8. Since there are four structures and only three unknowns, $P1$, $P2$, and Δ , it is possible to calculate the unknowns at each temperature from three structures and reconstruct the position of the fourth, or check the consistency of the method where all four structures are resolved. The values of $P1$ and $P2$ calculated from the experimental values of $P1 \pm \Delta$ and $P2 \pm \Delta$ are compared with the theoretical values (dashed line). Also Δ , the gap of the aluminum electrode, can be compared with the temperature variation of a BCS gap with $T_c = 1.6^\circ\text{K}$, as has been done in the lower part of Fig. 8. Remarkably good agreement is obtained."

(ii) The last seven lines of the right-hand column of p. 93 should be omitted.